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APPLICATION NO	, l	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/799,180	10/799,180 03/12/2004		Jack H. Yuan	SNDK.257US2	8152
36257	7590	07/12/2004		EXAMINER	
PARSON	S HSUE &	& DE RUNTZ LLP	ANYA, IGWE U		
655 MONT SUITE 180		Y STREET	ART UNIT	PAPER NUMBER	
SAN FRAI	-	CA 94111	2825		
				DATE MAILED: 07/12/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)					
Office Action Comments	10/799,180	YUAN ET AL.					
Office Action Summary	Examiner	Art Unit					
	Igwe U. Anya	2825					
The MAILING DATE of this communication app ars on the cov r sh et with the correspond nc address +- Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).							
Status							
1) Responsive to communication(s) filed on 12 Ma	arch 2004.						
2a) ☐ This action is FINAL . 2b) ☑ This	This action is FINAL. 2b)⊠ This action is non-final.						
3) ☐ Since this application is in condition for allowan	☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.							
Disposition of Claims							
4) Claim(s) 23-31 is/are pending in the application.							
4a) Of the above claim(s) is/are withdrawn from consideration.							
5) Claim(s) is/are allowed.							
	6)⊠ Claim(s) <u>23-31</u> is/are rejected.						
_	7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/or election requirement.							
Application Papers							
9)☐ The specification is objected to by the Examiner.							
10)⊠ The drawing(s) filed on <u>12 March 2004</u> is/are: a)⊠ accepted or b)⊡ objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
The ball of declaration is objected to by the Ex	aminer. Note the attached Office	Action or form P1O-152.					
Priority under 35 U.S.C. § 119							
 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) ☐ All b) ☐ Some * c) ☐ None of: 1. ☐ Certified copies of the priority documents have been received. 							
Certified copies of the priority documents have been received in Application No							
3.☐ Copies of the certified copies of the priority documents have been received in this National Stage							
application from the International Bureau (PCT Rule 17.2(a)).							
* See the attached detailed Office action for a list of the certified copies not received.							
Attachment(s)							
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	4) Interview Summary						
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)	Paper No(s)/Mail Da 5)	te atent Application (PTO-152)					
Paper No(s)/Mail Date 12/3/04.	6) Other:						

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 2. Claim 23 is rejected under 35 U.S.C. 102(e) as being anticipated by Shukuri et al. (US Patent 6614684).
- 3. Shukuri et al. teach a non-volatile memory, comprising, an array of memory cells formed on a first region of a substrate, circuit peripherals including decoders, drivers, and sense amplifiers formed on the second region of the substrate and does not overlap the first region; and

a 3000-angstrom deep trench formed in the substrate between the first and second regions region, and filled with dielectric.

Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the

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invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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- 5. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).
- 6. Claims 24 31 are rejected under 35 U.S.C. 103(a) as being unpatentable over lwasa (US Patent 5471423) in view of Shin et al. (US Patent 6180457).
- 7. Iwasa teaches a non-volatile memory, comprising, an array of charged storage elements formed on a semiconductor substrate (fig. 7), field dielectric material (12) formed over a surface of the semiconductor and positioned between charge storage elements, and electrical control gate (G) extending across tops of the array with a dielectric (col. 8 lines 56 64) positioned beneath and protruding downwards into slots formed over the field dielectric up to a depth of a top portion of the floating gate, and between adjacent charge storage elements. The row array (fig. 6) includes select gate (19) and source/drain regions(13). The top portions of the charge storage elements being wider than their bottom portions (fig. 7).
- 8. Iwasa lacks slots formed in the field dielectric.

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9. However, Shin et al. teach slots (fig. 17) formed in the field dielectric for

alignment (col. 8 lines 10 – 32).

10. Therefore, it would have been obvious to one of ordinary skill in the art to

incorporate the teachings of Shin et al. into the Iwasa reference for self-alignment.

11. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Igwe U. Anya whose telephone number is (571) 272-

1887. The examiner can normally be reached on M - F 8:30am - 5:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Matthew S. Smith can be reached on (571) 272-1907. The fax phone

number for the organization where this application or proceeding is assigned is 703-

872-9306.

Information regarding the status of an application may be obtained from the

Patent Application Information Retrieval (PAIR) system. Status information for

published applications may be obtained from either Private PAIR or Public PAIR.

Status information for unpublished applications is available through Private PAIR only.

For more information about the PAIR system, see http://pair-direct.uspto.gov. Should

you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

Igwe U. Anya Examiner

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IA

June 27, 2004

WATTHEW SMITH
SUPERVISORY PATENT EXAMINER

TECHNOLOGY CENTER 2800